Supporting Information: Intercalation of Thin Film Gd-doped Ceria Barrier Layers in Electrolyte Supported Solid Oxide Cells: Physico-chemical Aspects

Matthias Riegraf,^a Feng Han,^{a,*} Noriko Sata, Rémi Costa^a

^aGerman Aerospace Centre (DLR), Institute of Engineering Thermodynamics,

Pfaffenwaldring 38-40, 70569 Stuttgart, Germany

*Corresponding author: E-mail: feng.han@dlr.de

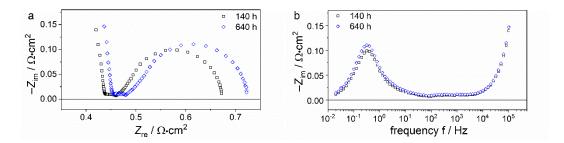


Figure S1. Nyquist and imaginary impedance plots at 140 h and 640 h of durability test 1 of the cell with 0.3 µm thick barrier layer.

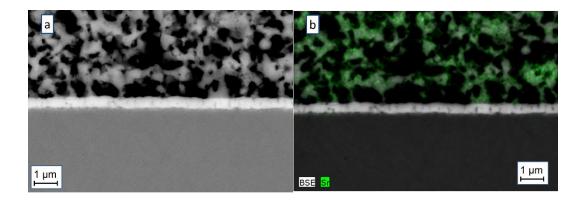


Figure S2. Post mortem a) SEM and b) EDX images of the LSCF/CGO/YSZ interface of the cell with 0.5 μ m thick CGO layers of the first durability test.

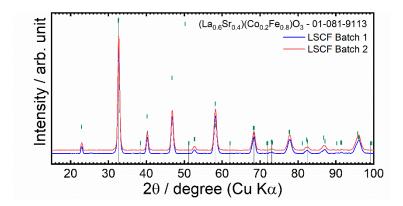


Figure S3. XRD patterns of the LSCF inks used in batch 1 and 2.

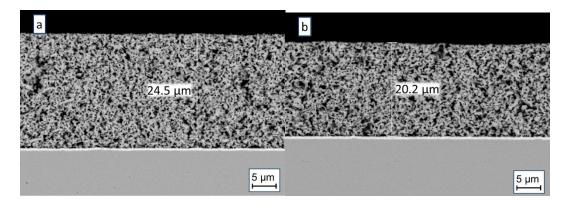


Figure S4. Post mortem SEM images of the LSCF/CGO/YSZ interface of the cells with 0.5 μ m thick CGO layers in a) batch 1 and b) batch 2.